

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Keiichiro KATA et al.

Title:

PROCESS FOR MANUFACTURING SEMICONDUCTOR DEVICE

AND SEMICONDUCTOR WAFER

Application No.:

10/645,782

Filing Date:

8/22/2003

Examiner:

Mark Prenty

Art Unit:

2822

## AMENDMENT AND REPLY UNDER 37 C.F.R. 1.173

## Mail Stop Amendment

Commissioner of Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

This amendment and reply is being filed in response to an Office Action dated January 19, 2006, for the above-identified application.

A petition and fee for a one-month extension of time is being submitted concurrently herewith.

Amendments to the Claims begin on page 2 of this document.

Remarks/Arguments begin on page 7 of this document.

Please amend the application as follows:

05/01/2006 JADDO1 00000021 10645782

01 FC:1201 02 FC:1251

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